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Attorney Docket No. 015675.P322

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re the Patent Application of:

CLAUDE CHAPPERT

Serial No. 09/600,546

Filed: July 12, 2000

For: MAGNETIC ETCHING PROCESS,  
ESPECIALLY FOR MAGNETIC OR  
MAGNETOOPTIC RECORDING

Examiner: Angebranndt, Martin J.

Art Unit: 1756

**SUPPLEMENTAL AMENDMENT AND RESPONSE  
TO OFFICE ACTION**Box Amendments  
Commissioner for Patents  
Washington, D.C. 20231-9998

Dear Sir:

In response to an Office Action having a mailing date of November 26, 2001, Applicant respectfully requests the Examiner to enter the following supplemental amendment and reconsider the above-identified patent application in view of the accompanying remarks.

**IN THE CLAIMS****Please amend Claim 1 as follows:**

*Claim 1*  
1. (Amended) Writing process on a multi-layer material composed of thin layers, in which said material is irradiated by means of a beam of light ions, having an energy of the order of or less than a hundred keV, wherein the material is a thin-layers material comprising buried layers deposited on a substrate, wherein one or more regions having individual sizes of the order of 1 micrometer or less are selectively

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